Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

1. (currently amended) A display device comprising ~~characterized in that~~:

in a pixel region formed ~~on~~ over a substrate, a first pixel electrode formed of a light transmissive conductive layer is formed in one optical transmissive region, which is formed by partitioning the pixel region, and a second pixel electrode formed of a non-light transmissive conductive film is formed on the remainder of the partitioned pixel region to form a light reflective region;

~~the~~ said first pixel electrode is positioned as a lower layer with respect to an insulation film, and, a hole is formed in ~~the~~ said insulation film in a region corresponding to ~~the~~ said light transmissive region so as to expose ~~the~~ said first pixel electrode, and ~~the~~ said second pixel electrode is formed ~~on~~ at least one of over and in a light reflective region of ~~the~~ said insulation film; and

at least a portion corresponding to a side wall surface of the hole formed in ~~the~~ said insulation film is arranged in relation to a light shielding film ~~shielded from light~~.

2. (currently amended) A display device according to claim 1, wherein ~~the~~ said first pixel electrode and ~~the~~ said second pixel electrode are formed ~~on~~ over one of a pair of substrates which are arranged to face each other in an opposed manner with liquid crystal disposed therebetween, and ~~a~~ said light shielding film ~~which is positioned below the insulation film~~ is formed over said one substrate of said pair of

substrates ~~provided to at least the portion corresponding to the side wall surface of the hole formed in the insulation film~~.

3. (currently amended) A display device according to claim 1, wherein ~~the~~ said first pixel electrode and ~~the~~ said second pixel electrode are formed ~~on~~ over one of a pair of substrates which are arranged to face each other in an opposed manner with liquid crystal disposed therebetween, and ~~a~~ said light shielding film is formed over another substrate of said pair of substrates~~provided to a portion corresponding to a side wall surface of a hole formed in the insulation film of the other substrate of the respective substrates~~.

4. (currently amended) A display device ~~characterized in that~~ comprising:

~~on~~ over one of a pair of substrates which are arranged to face each other with liquid crystal disposed therebetween, a plurality of ~~juxtaposed~~ gate signal lines and a plurality of juxtaposed drain signal lines which cross ~~the~~ said respective gate signal lines are formed;

regions surrounded by said gate signal lines and said drain signal lines ~~these respective signal lines~~ constitute pixel regions, and each pixel region includes a switching element, ~~which is operated in response to a scanning signal received from a gate signal line,~~ and a pixel electrode to which a video signal is supplied from ~~a~~ one of said drain signal ~~line~~ lines through ~~the~~ said switching element;

~~the~~ said pixel electrode is constituted of a first pixel electrode formed of a light transmissive conductive layer, which is formed in a light transmissive region which constitutes one region resulting from partitioning the pixel region, and a second pixel electrode formed of a non-light transmissive conductive film, which is formed in a

light reflective region which constitutes the remainder of ~~the~~ said pixel region after partitioning ~~the~~ said pixel region;

~~the~~ said first pixel electrode is positioned as a lower layer with respect to an insulation film, a hole is formed in the insulation film in a region corresponding to ~~the~~ said light transmissive region so as to expose ~~the~~ said first pixel electrode, ~~the~~ said second pixel electrode is formed in ~~the~~ light reflective region of ~~the~~ said insulation film; and

a light shielding film, which is positioned as a layer below ~~the~~ said insulation film, is provided to at least a portion corresponding to a side wall surface of the hole formed in ~~the~~ said insulation film.

5. (currently amended) A display device according to the claim 4, wherein ~~the~~ said light shielding film is made of the same material as the material of ~~the~~ said gate signal lines.

6. (currently amended) A display device ~~characterized in that~~ comprising:

~~on~~ over one of a pair of substrates which are arranged to face each other with liquid crystal therebetween, a plurality of ~~juxtaposed~~ gate signal lines and a plurality of ~~juxtaposed~~ drain signal lines which cross ~~the~~ said ~~respective~~ gate signal lines are formed;

regions surrounded by said gate signal lines and said drain signal lines ~~the respective signal lines~~ constitute pixel regions, and each pixel region includes a switching element, ~~which is operated in response to a scanning signal received from the gate signal line,~~ and a pixel electrode to which a video signal is supplied from ~~a~~ one of said drain signal ~~line~~ lines through ~~the~~ said switching element;

~~the~~ said pixel electrode is constituted of a first pixel electrode formed of a non-light transmissive conductive layer, which is formed in a light reflective region surrounding a light transmissive region, and a second pixel electrode formed of a light transmissive conductive layer which is formed ~~on~~ over the light reflective region;

~~the~~ said second pixel electrode is positioned as a lower layer with respect to an insulation film, a hole is formed in ~~the~~ said insulation film in a region corresponding to ~~the~~ said light transmissive region so as to expose ~~the~~ said second pixel electrode, ~~the~~ said first pixel electrode is formed in ~~the~~ a light reflective region of ~~the~~ said insulation film;

a light shielding film, which is positioned as a layer below ~~the~~ said insulation film, is provided to at least a portion corresponding to a side wall surface of ~~the~~ said hole formed in ~~the~~ said insulation film; and

~~the~~ said light shielding film is formed as a layer below ~~the~~ said second pixel electrode, and, at the same time, there exists a portion where ~~the~~ said light shielding layer is not formed at a part of the portion corresponding to ~~the~~ said side wall surface of ~~the~~ said hole formed in ~~the~~ said insulation film.

7. (currently amended) A display device ~~characterized in that~~ comprising:

~~on~~ over one of a pair of substrates which are arranged to face each other with liquid crystal therebetween, a plurality of ~~juxtaposed~~ gate signal lines and a plurality of ~~juxtaposed~~ drain signal lines which cross ~~the~~ said ~~respective~~ gate signal lines are formed;

regions surrounded by said gate signal lines and said drain signal lines ~~these respective signal lines~~ constitute pixel regions, and each pixel region includes a switching element, ~~which is operated in response to a scanning signal received from~~

~~a gate signal line,~~ and a pixel electrode to which a video signal is supplied from ~~a~~ one of said drain signal ~~line~~ lines through ~~the~~ said switching element;

~~the~~ said pixel electrode is constituted of a first pixel electrode formed of a non-light transmissive conductive layer, which is formed in a light reflective region surrounding a light transmissive region and a second pixel electrode formed of a light transmissive conductive layer which is formed on the light reflective region;

~~the~~ said second pixel electrode is positioned as a lower layer with respect to an insulation film, a hole is formed in ~~the~~ said insulation film in a region corresponding to ~~the~~ said light transmissive region so as to expose ~~the~~ said second pixel electrode, ~~the~~ said first pixel electrode is formed in ~~the~~ a light reflective region of ~~the~~ said insulation film;

a light shielding film, which is positioned as a layer below ~~the~~ said insulation film, is provided to at least a portion corresponding to a side wall surface of ~~the~~ said hole formed in ~~the~~ said insulation film; and

~~the~~ said light shielding film is made of a material similar to the material of ~~the~~ said gate signal lines and is formed as a layer below ~~the~~ said second pixel electrode, and, at the same time, there exists a portion where ~~the~~ said light shielding layer is not formed at a part of the portion corresponding to the side wall surface of ~~the~~ said hole formed in ~~the~~ said insulation film, and this portion includes a portion which is close to ~~the~~ said switching element.

8. (new) A display device according to claim 1,

wherein at least the portion corresponding to the side wall surface of the hole formed in said insulating film is overlapped with said light shielding film.

9. (new) A display device according to claim 1,

wherein each said pixel region is constituted by surrounding gate signal lines and drain signal lines, and each said pixel region includes a switching element, and a pixel electrode to which a video signal is supplied from one of said drain signal lines through said switching element;

said light shielding film exists a portion where a light shielding layer thereof is not formed at a part of the portion corresponding to the side wall surface of said hole formed in said insulation film, and the portion includes a part thereof which is close to said switching element.

10. (new) A display device according to claim 9,

wherein said light shielding film is made of a material similar to the material of said gate signal lines.

11. (new) A display device according to claim 10,

wherein said light shielding film is formed as a layer below said second pixel electrode.

12. (new) A display device according to claim 1,

wherein each of said pixel region is constituted by surrounding gate signal lines and said drain signal lines, and each said pixel region includes a switching element, and a pixel electrode to which a video signal is supplied from one of said drain signal lines through said switching element;

said light shielding film exists corresponding to the side wall surface of said hole formed in said insulation film.

13. (new) A display device according to claim 12,

wherein said light shielding film is made of a material similar to the material of said gate signal lines.

14. (new) A display device according to claim 13,

wherein said light shielding film is formed as a layer below said second pixel electrode.